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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/596,671	06/21/2006	Yuichiro Shindo	OGOSH55USA	9231
270 7590 11/18/2010 HOWSON & HOWSON LLP 501 OFFICE CENTER DRIVE			EXAMINER	
			ROE, JESSEE RANDALL	
SUITE 210 FORT WASHINGTON, PA 19034		ART UNIT	PAPER NUMBER	
10111 1111111	1001 1111111111111111111111111111111111			
			NOTIFICATION DATE	DELIVERY MODE
			11/18/2010	ELECTRONIC

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

docketing@howsonandhowson.com

Application No. Applicant(s) 10/596,671 SHINDO, YUICHIRO Office Action Summary Examiner Art Unit JESSEE ROE -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 01 November 2010. 2a) This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 1-4 and 7-13 is/are pending in the application. 4a) Of the above claim(s) 3.4 and 9-13 is/are withdrawn from consideration. 5) Claim(s) _____ is/are allowed. 6) Claim(s) 1,2,7 and 8 is/are rejected. 7) Claim(s) _____ is/are objected to. 8) Claim(s) _____ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are; a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abevance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. Attachment(s)

U.S. Patent and Trademark Office PTOL-326 (Rev. 08-06)

1) Notice of References Cited (PTO-892)

Paper No(s)/Mail Date 21 June 2006.

Notice of Draftsperson's Patent Drawing Review (PTO-948)
 Minormation Discussive Statement(s) (PTO/SB/06)

Interview Summary (PTO-413)
 Paper No(s)/Mail Date.

6) Other:

5) Notice of Informal Patent Application

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DETAILED ACTION

Status of the Claims

Claims 1-4 and 7-13 are pending wherein claims 1-2 and 7-8 are currently under examination and claims 3-4 and 9-13 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a non-elected method for manufacturing a Ni-Pt alloy. Applicant's election of claims 1-2 and 7-8 without traverse in the Reply filed 1 November 2010 is acknowledged.

Specification

The abstract of the disclosure is objected to because is contains more than 150 words. Correction is required. See MPEP § 608.01(b).

Applicant is reminded of the proper language and format for an abstract of the disclosure.

The abstract should be in narrative form and generally limited to a single paragraph on a separate sheet within the range of 50 to 150 words. It is important that the abstract not exceed 150 words in length since the space provided for the abstract on the computer tape used by the printer is limited. The form and legal phraseology often used in patent claims, such as "means" and "said," should be avoided. The abstract should describe the disclosure sufficiently to assist readers in deciding whether there is a need for consulting the full patent text for details.

The language should be clear and concise and should not repeat information given in the title. It should avoid using phrases which can be implied, such as, "The disclosure concerns," "The disclosure defined by this invention," "The disclosure describes," etc.

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Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1 and 7 are rejected under 35 U.S.C. 102(a) or 35 U.S.C. 102(b) as being anticipated by Chi et al. (US 6,531,396).

In regards to claims 1 and 7, Chi et al. ('396) discloses depositing a nickel/platinum layer on a semiconductor substrate from a sputtering target wherein the nickel/platinum layer (and therefore the sputtering target) has a nickel content between 90 and 99% and a platinum content between 1 and 10% (col. 2). Thus, the sputtering target would inherently have nickel within the range of 90 to 99% and platinum within the range of 1 to 10%.

With respect to the recitations "superior in workability" and "having a Vickers hardness of 40 to 90" in claim 1 and "having a Vickers hardness of 40 to 90" in claim 7, the Examiner notes that because Chi et al. ('396) discloses the same sputtering target composition as the instant invention, the claimed workability and hardness would be expected in the sputtering target composition of Chi et al. ('396). MPEP 2112.01 I.

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-2 and 7-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Chi et al. (US 6,531,396).

In regards to claims 1 and 7, Chi et al. ('396) discloses depositing a nickel/platinum layer on a semiconductor substrate from a sputtering target wherein the nickel/platinum layer (and therefore the sputtering target) has a nickel content between 90 and 99% and a platinum content between 1 and 10% (col. 2). Thus, it would have been obvious to one of ordinary skill in the art to select a sputtering target having nickel within the range of 90 to 99% and platinum within the range of 1 to 10%, which is prima facie evidence of obviousness. MPEP 2144.05 I.

With respect to the recitation "having a purity of 99.99% or higher" in claims 2 and 8, Chi et al. ('396) discloses either using a nickel-platinum alloy target or cosputtering a pure nickel target and a pure platinum target (cols. 1 and 2). Chi et al. ('396), therefore desires only depositing pure materials on the semiconductors.

Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to only use pure metals in the sputtering targets that would be used in the semiconductors of Chi et al. ('396). Alternatively, Chi et al. ('396) does not specify that the Ni-Pt alloy would have "a purity of 99.99% or higher" as in claims 2 and

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However, merely purifying a prior art product would not be sufficient to patentably distinguish from that prior art product. MPEP 2144.04 (VII).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jessee Roe whose telephone number is (571)272-5938. The examiner can normally be reached on Monday-Thursday and alternate Fridays 7:00 AM - 4:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Roy V. King can be reached on (571) 272-1244. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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/Jessee Roe/ Examiner, Art Unit 1733